

# **Surface Analysis of Liquid Gallium**

Bob Bastasz and Josh Whaley

Sandia National Laboratories  
Livermore, California, USA

## **Outline**

- **Introduction, some properties of Ga**
- **Surface composition data on Ga**
- **Adsorption of deuterium on Ga**
- **Comparison with Li and Sn, summary**

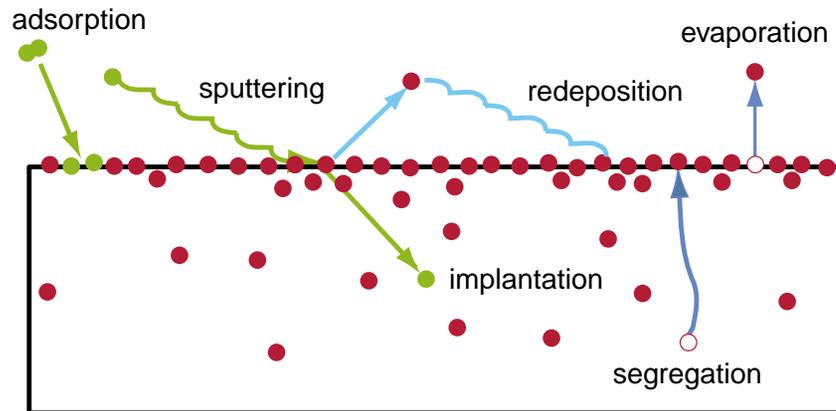
# Surface studies of plasma-facing liquids

Issue: What comprises the surface seen by the plasma?

Need: Experimental data on liquid surfaces needed to properly model conditions that will exist in a fusion reactor.

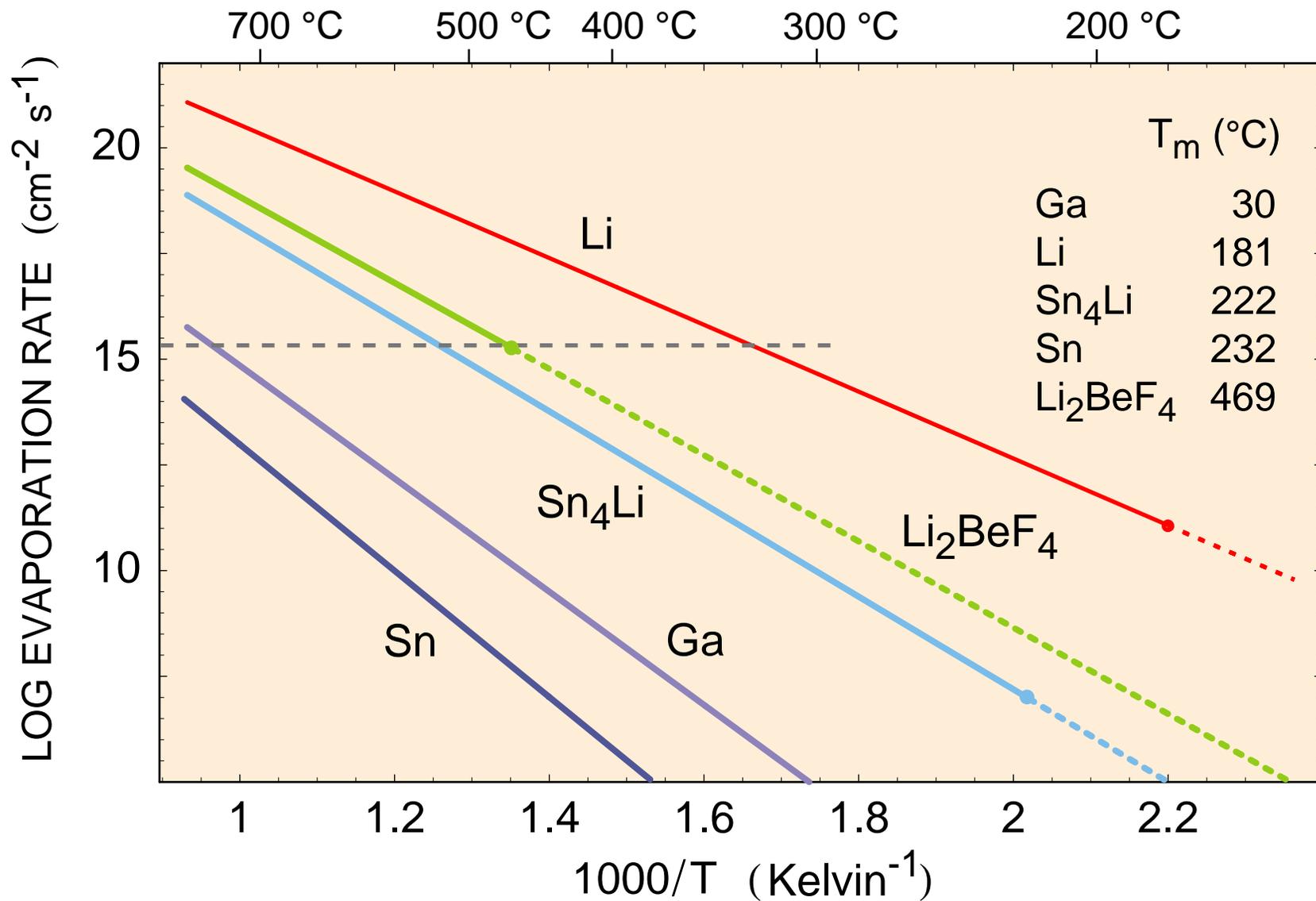
Tasks:

- Examine surface composition of candidate liquids
- Consider how surface composition will evolve during plasma exposure due to combined effects of:



- > evaporation
- > sputtering / redeposition
- > segregation
- > adsorption / implantation.

# Evaporation rates for candidate liquids



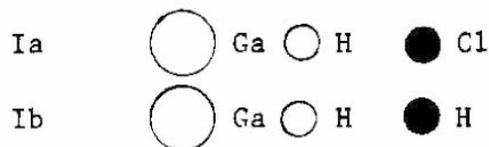
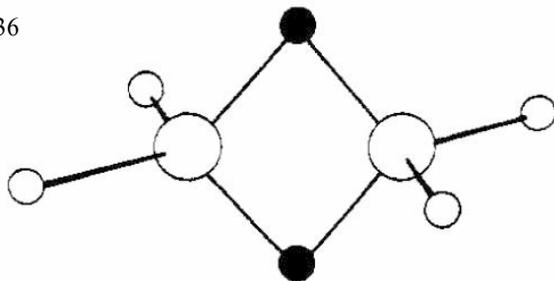
## Melting points and densities of some Li, Ga, and Sn containing materials

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<u>material</u>	<u>melting point (°C)</u>	<u>density (g/cm<sup>3</sup>)</u>
⇒ SnH <sub>4</sub>	-146	
⇒ Ga <sub>2</sub> H <sub>6</sub>	- 50	
⇒ Ga	29.76	5.91
Li	180.5	0.534
Sn <sub>4</sub> Li	222	
Sn	231.93	7.265
LiH	688.7	0.78
Li <sub>7</sub> Sn <sub>2</sub>	783	
Li <sub>2</sub> O	1570	2.013
SnO <sub>2</sub>	1630	6.85
⇒ Ga <sub>2</sub> O <sub>3</sub>	1807	6.0

# Gallium hydride exists, but is not easily formed.

1936



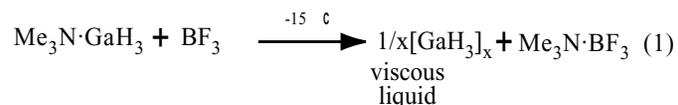
## Gallane at Last! Synthesis and Properties of Binary Gallium Hydride

Anthony J. Downs,\* Michael J. Goode,+ and Colin R. Pulham

*Inorganic Chemistry Laboratory  
University of Oxford, Oxford, OX1 3QR U.K.*

*Received October 12, 1988*

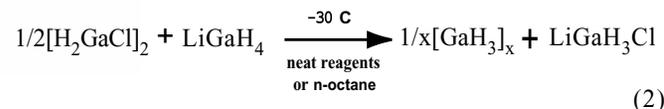
The uncoordinated binary hydride of gallium is terra incognita beyond the vapor-phase transients  $\text{GaH}^{1a}$  and  $\text{GaH}_3^{1b}$ . This has not been for want of exploration. As early as 1941 Wiberg et al. laid claim to the synthesis of the free hydride via two routes<sup>2</sup>. Neither stood the test of subsequent reexamination<sup>3a</sup>, but Greenwood and Wallbridge<sup>3b</sup> presented analytical and spectroscopic evidence for displacement reaction 1. More recent studies,



*J. Am. Chem. Soc.* **1989**, *111*, 1936-1937

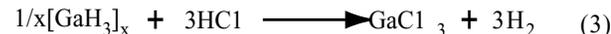
## Gallane first isolated in 1989

but **Ia** is also a liquid even at quite low temperatures and therefore susceptible to more efficient mixing with the hydride ion source ( $\text{MGaH}_4$ ). We find that **Ia** reacts in vacuo with freshly prepared  $\text{LiGaH}_4$  at  $-30^\circ\text{C}$  to give not only substantial quantities of elemental gallium and hydrogen but also a volatile product, shown to be gallane, typically in amounts of 4-40 mg and yields of ca. 5% based on eq 2. Operations were carried out at a pressure of



$< 10^{-4}$  mmHg in an all-glass apparatus which had been pre-conditioned by heating under continuous pumping, with short distillation paths and the maintenance of all glassware to which the gallane had access at temperatures  $< -20^\circ\text{C}$ . Gallane condenses as a white solid which melts at ca.  $-50^\circ\text{C}$  and has a vapor pressure at  $-63^\circ\text{C}$  of ca. 1 mm Hg.

(a) **Elemental analysis** confirmed that the compound contained no chlorine, only gallium and hydrogen. The reaction with an excess of anhydrous  $\text{HCl}$  at  $-95^\circ\text{C}$  resulted in the quantitative formation of  $\text{GaCl}_3$  and  $\text{H}_2$  in accordance with eq 3.



(b) **IR Spectrum.** A film of the annealed solid compound at 77 K displayed an IR spectrum resembling that of the condensate formed by the vapors derived from the reaction of an excess of  $\text{NaGaH}_4$ , with  $\text{GaCl}_3$ , with three main absorptions at 1978 (s), 1705 (s, br), and  $550\text{ cm}^{-1}$  (s, br), which shifted to 1422, 1200, and  $400\text{ cm}^{-1}$ , respectively, for the perdeuterated compound. Very different spectra were exhibited by the vapor (Figure 1) or by solid matrices formed by codepositing the vapor with an excess of Ar, Kr, or  $\text{N}_2$  at ca. 20 K. Here the pattern and energies of the absorptions—with two distinct features near  $2000\text{ cm}^{-1}$  attributable

# Surface analysis of liquid gallium

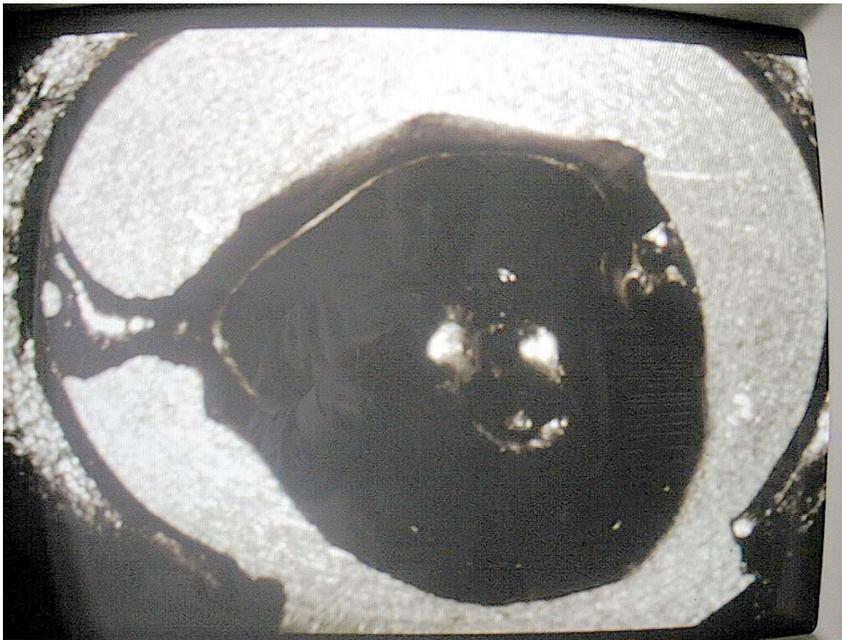
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- Liquid Ga was prepared by melting sputter-cleaned, high-purity Ga in vacuum.
- The composition of the liquid Ga surface was measured using an ion beam probe for both:
  - low-energy ion scattering (LEIS)
  - direct recoil spectroscopy (DRS).
- Surface composition measurements were obtained from 25 °C up to 500 °C.
- Clean liquid Ga surfaces were examined during exposure to molecular D<sub>2</sub>(g) and atomic D.

# Appearance of solid and liquid Ga surface

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solid



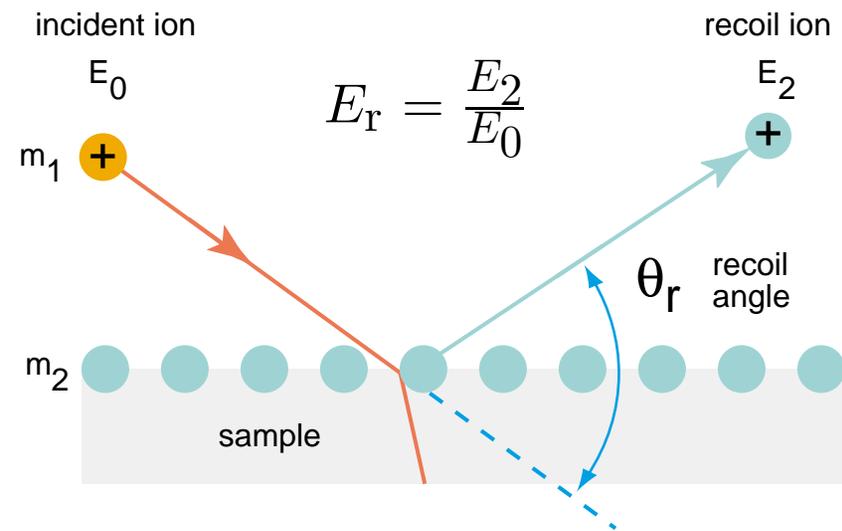
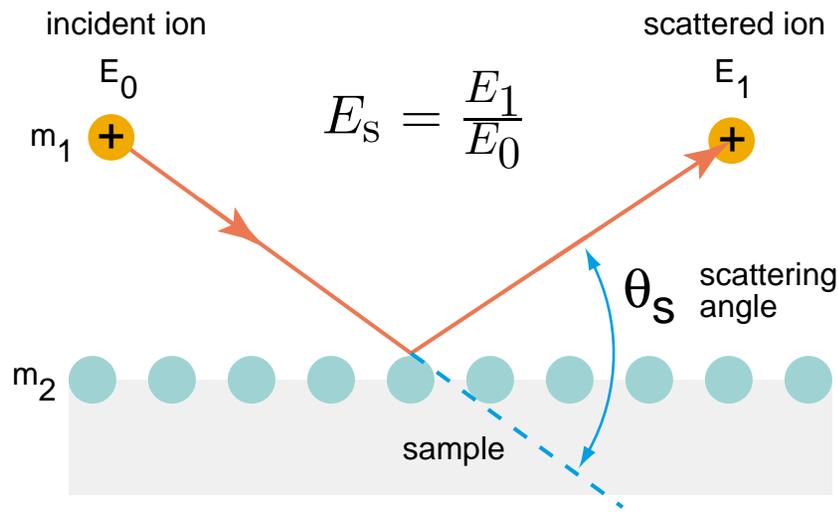
$\approx 25\text{ }^{\circ}\text{C}$

liquid



$\approx 100\text{ }^{\circ}\text{C}$

# Surface measurements consist of aiming an ion beam at the surface and measuring the energy of scattered and recoiled ions.

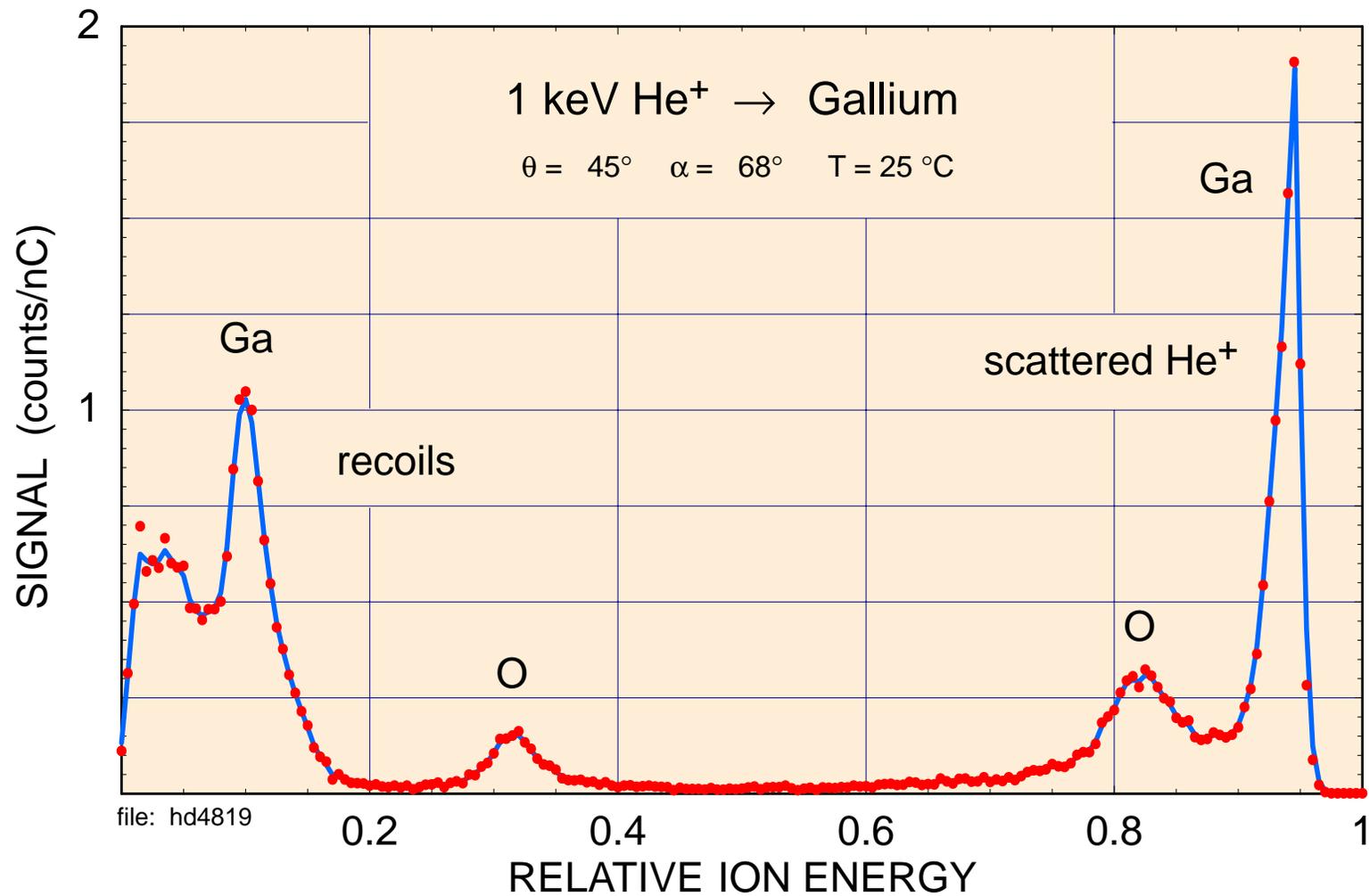


$$m_2 = m_1 \frac{1 + E_s - 2\sqrt{E_s} \cos \theta_s}{1 - E_s - Q_n}$$

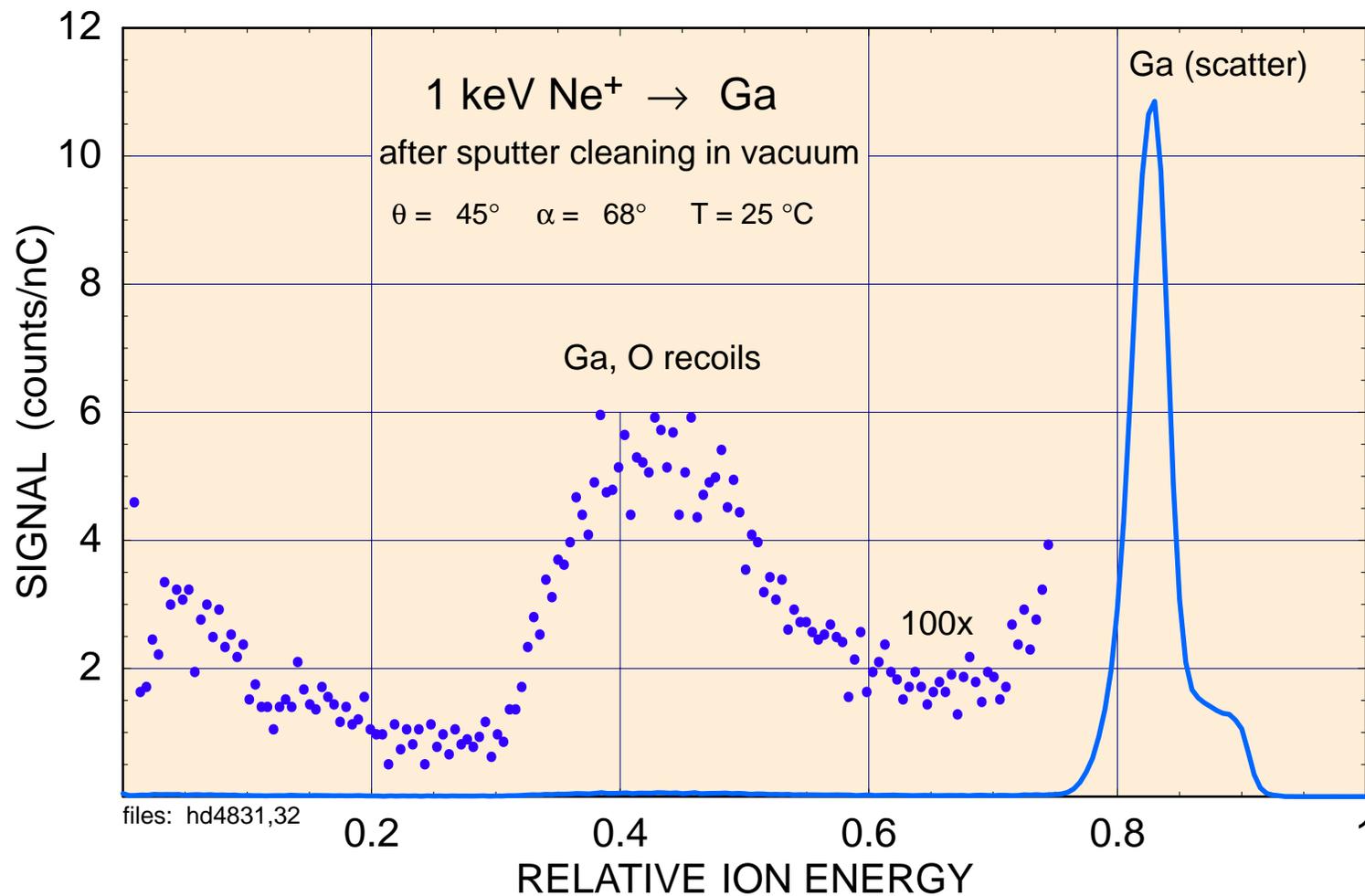
$$m_2 = m_1 \frac{(\cos \theta_r \pm \sqrt{\cos^2 \theta_r - E_r - Q_n})^2}{E_r}$$

$Q_n$  = inelastic energy loss

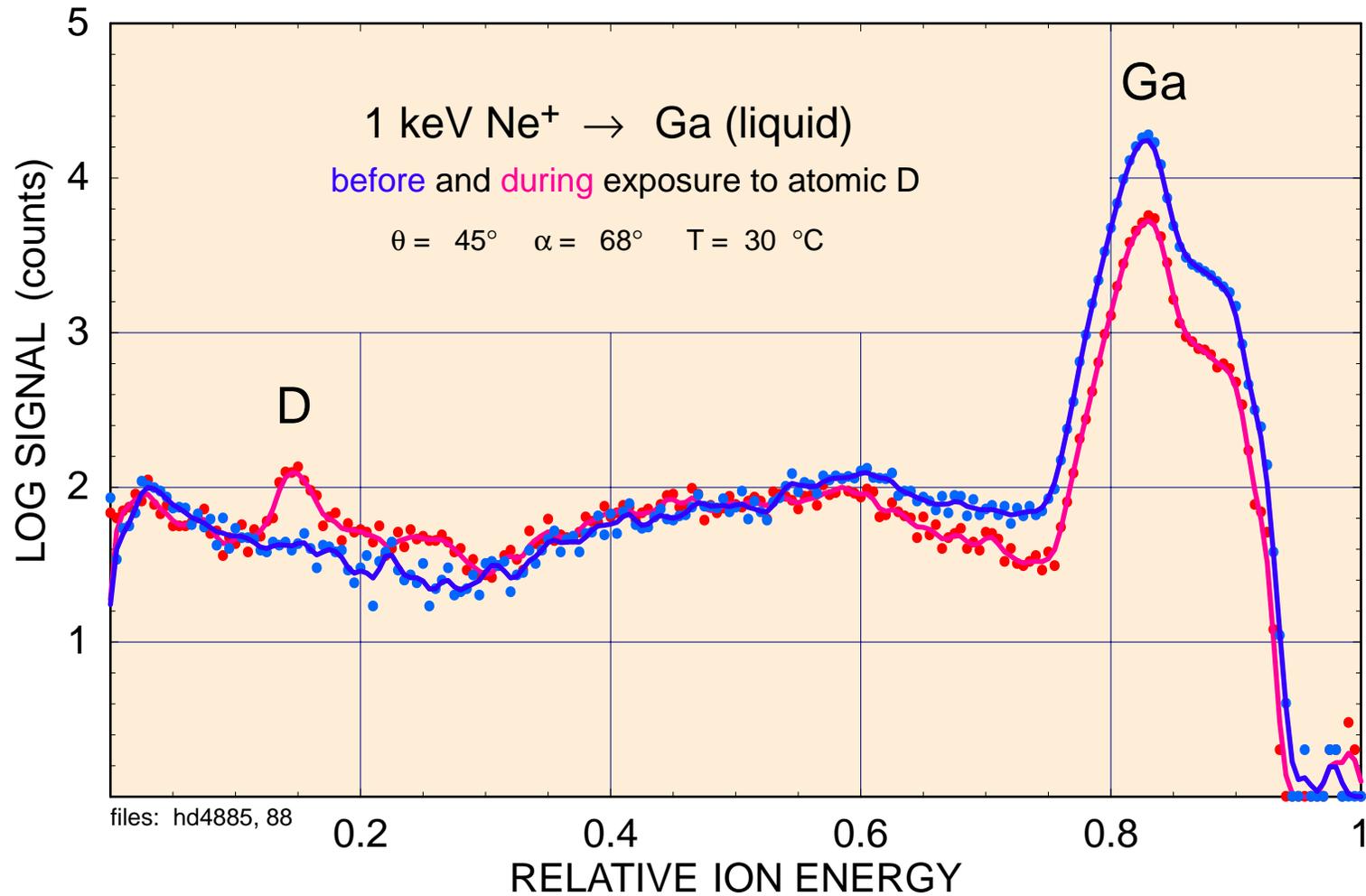
# Oxygen is initially present on the Ga surface.



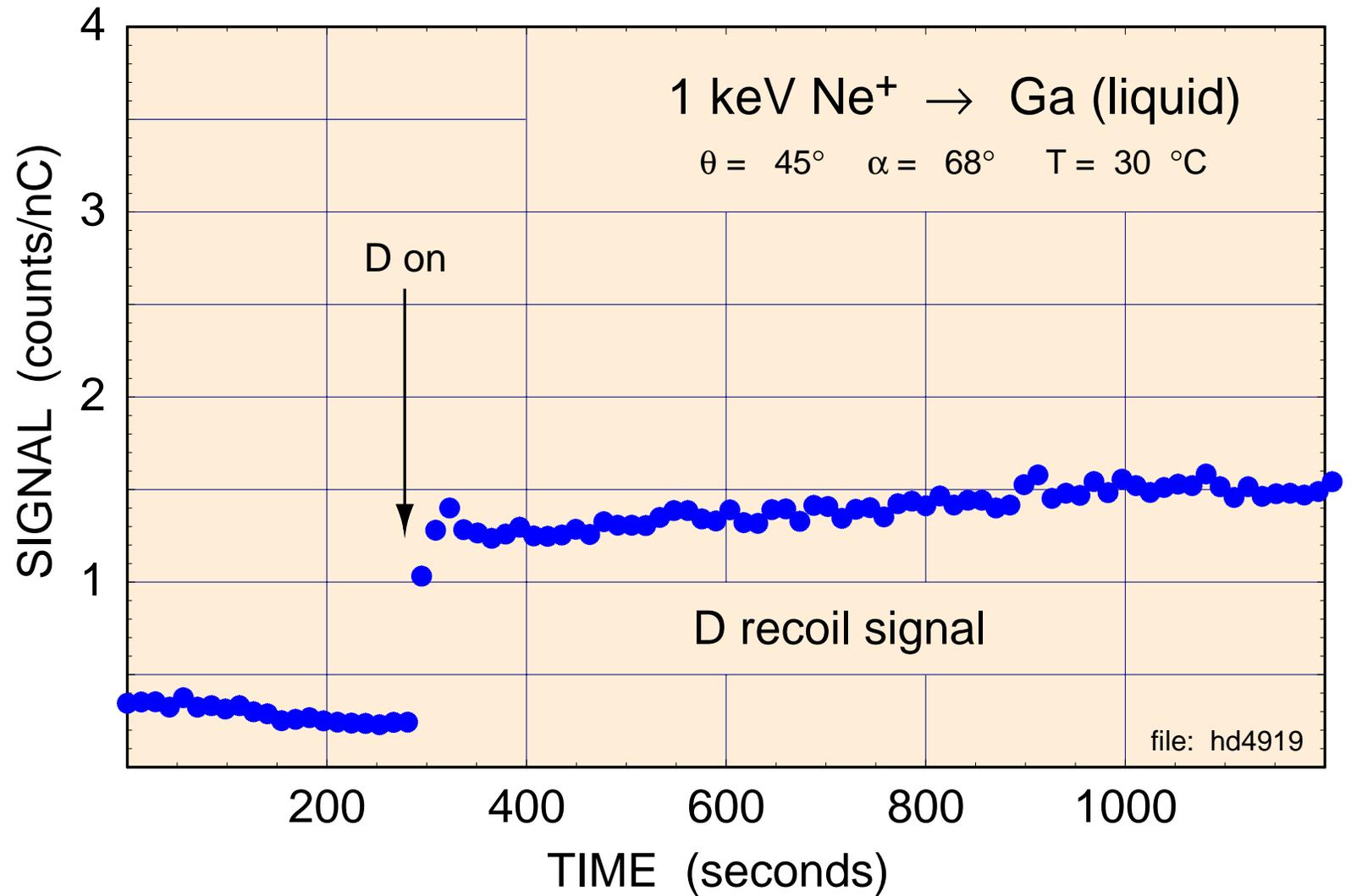
# Surface of sputtered Ga in vacuum is clean.



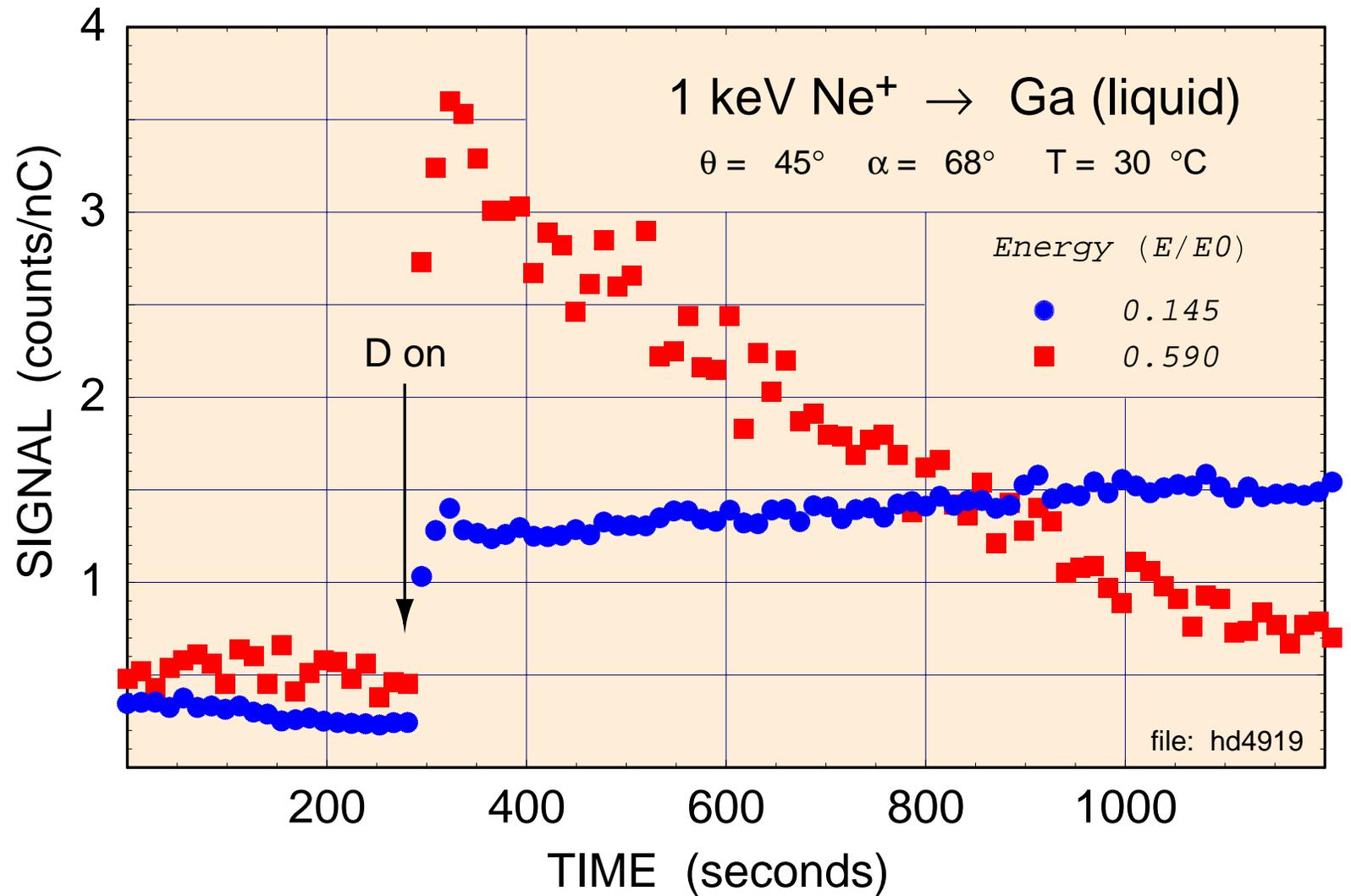
# Atomic D adsorbs on liquid Ga at 30 °C.



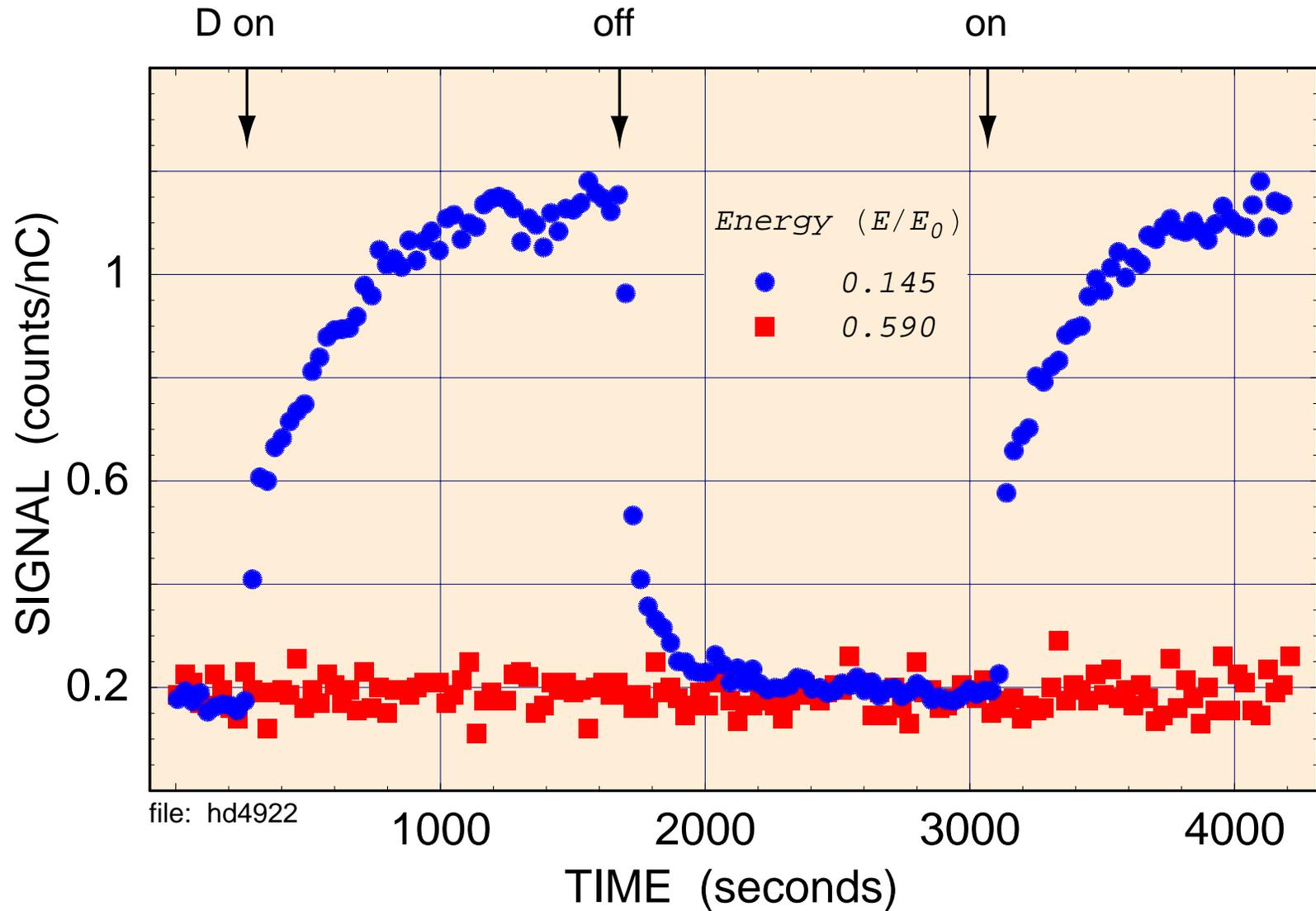
# Surface D level rises during D exposure.



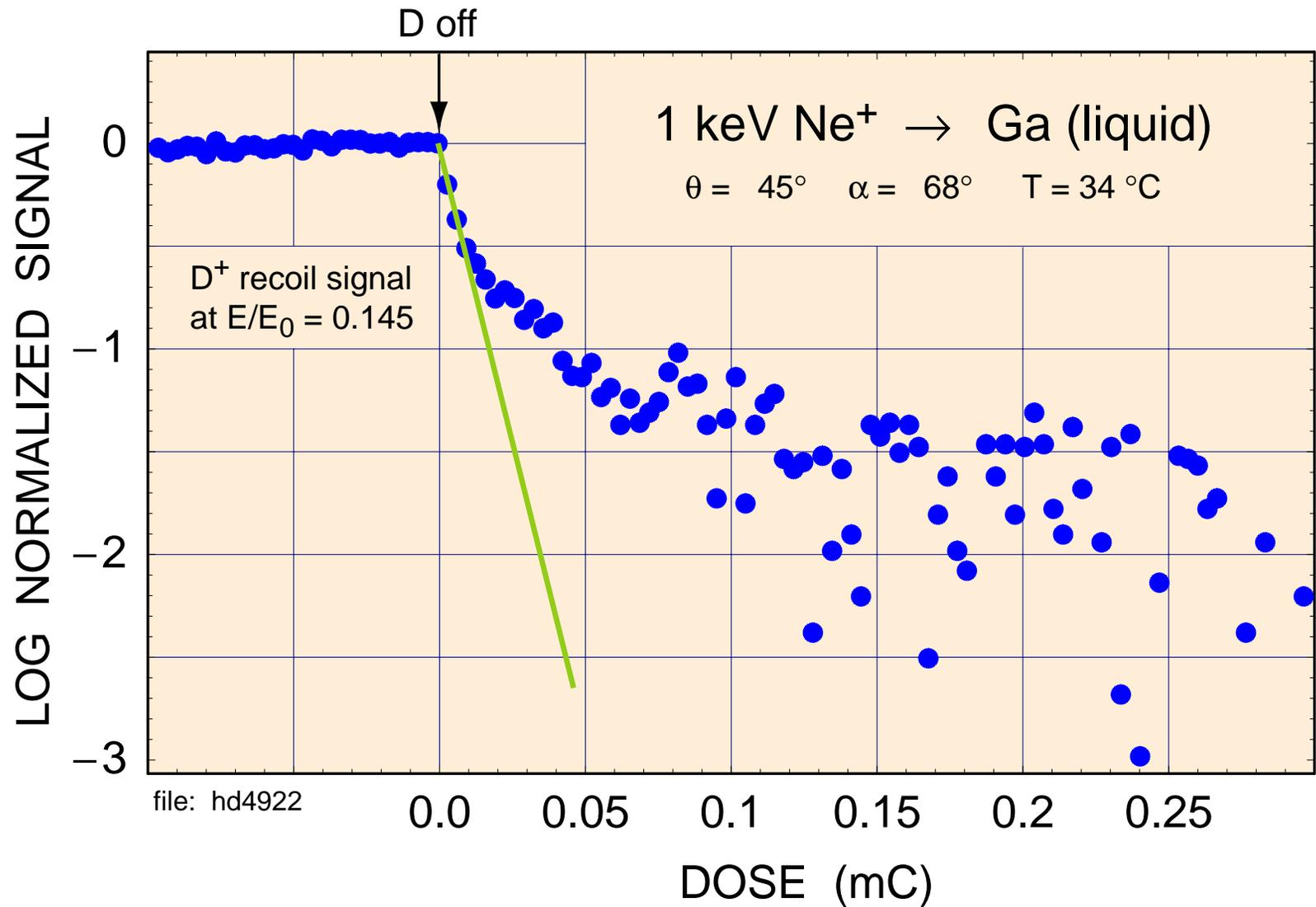
# A transient feature appears with D exposure.



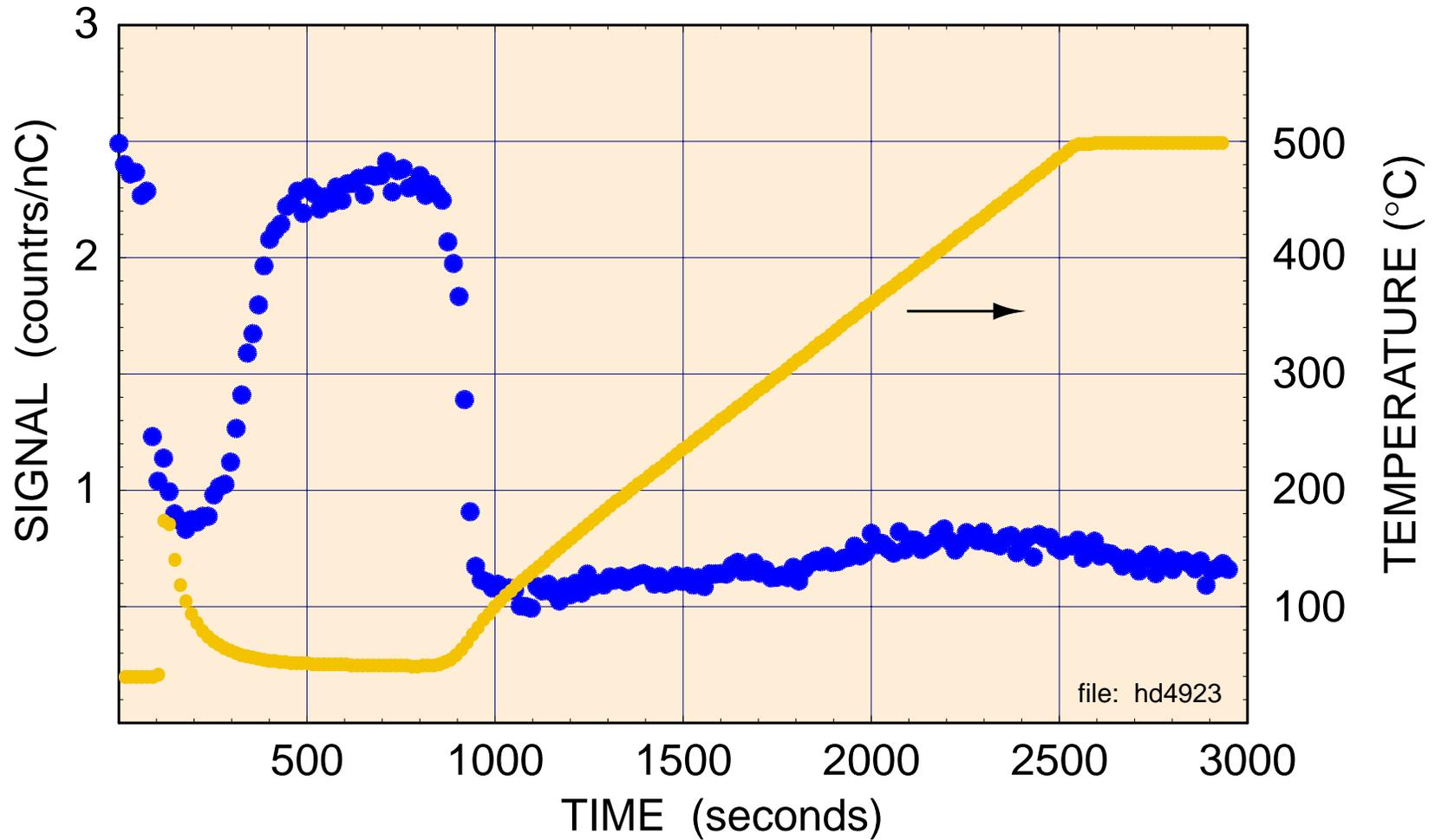
# D adsorption is clearly observed on clean Ga.



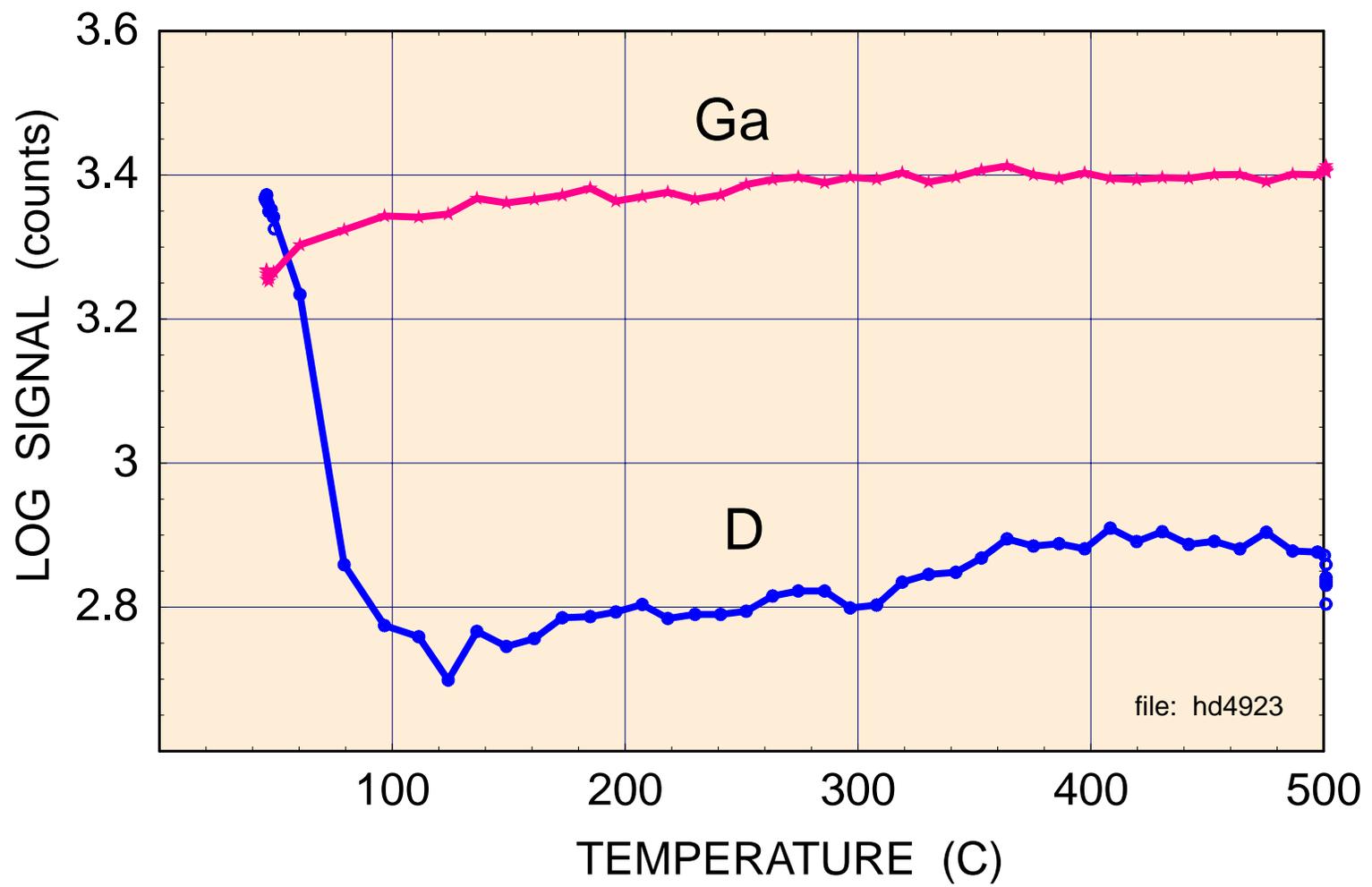
# D signal decay gives IID cross section.



# D disappears from Ga surface above 100 °C.



# Temperature dependence of D on Ga surface



file: hd4923

# D<sub>2</sub> and D adsorption on Li, Ga, and Sn

Adsorbed D is found under the following conditions:

during exposure to D <sub>2</sub>		
<i>material</i>	<i>solid</i>	<i>liquid</i>
Li	Yes	Yes
Ga	No	No
Sn	No	No

during exposure to D		
<i>material</i>	<i>solid</i>	<i>liquid</i>
Li	Yes	Yes
Ga	?	Yes
Sn	Yes	No

# Summary

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- No adsorption of molecular  $D_2$  on Ga observed.
  - Atomic D adsorbs on liquid Ga surface at  $\leq 100$  °C.
  - Almost no D seen on surface at higher temperatures (up to 500 °C).
  - Surface D efficiently removed by ion impact.
  - Surface contamination of liquid Ga may be an issue.
- ⇒ With respect to H isotopes, liquid Ga surfaces appear to be less reactive than Li, but more reactive than Sn.

## **Future work**

- Measure D re-emission from D loaded Ga.
- Examine contamination effects in more detail.
- Evaluate the cross section for ion impact desorption of D from Ga.
- Explore detection of He on liquid metal surfaces by LEIS.